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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/687,498	03/25/2004	Lin Wang	06401.00418	9050
22908	7590 08/08/2006		EXAMINER	
BANNER & WITCOFF, LTD.			HUSON, MONICA ANNE	
TEN SOUTH SUITE 3000	WACKER DRIVE		ART UNIT	PAPER NUMBER
CHICAGO, I	L 60606		1732	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)				
Office Action Summary		10/687,498	WANG ET AL.				
		Examiner	Art Unit				
		Monica A. Huson	1732				
Period fo	The MAILING DATE of this communication ap or Reply	opears on the cover sheet with the o	correspondence address				
WHIC - Externafter - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLICATION OF THE MAILING DESCRIBION OF	DATE OF THIS COMMUNICATION  .136(a). In no event, however, may a reply be tired will apply and will expire SIX (6) MONTHS from te, cause the application to become ABANDONE	N. mely filed the mailing date of this communication. ED (35 U.S.C. § 133).				
Status							
1)[🛛	Responsive to communication(s) filed on 15 (	October 2003					
2a)[	This action is <b>FINAL</b> . 2b)⊠ This action is non-final.						
<i>′</i> =							
-/-	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Dispositi	on of Claims		·				
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	☐ Claim(s) <u>1-6</u> is/are pending in the application.						
	4a) Of the above claim(s) is/are withdrawn from consideration.						
_	5)  Claim(s) is/are allowed. 6)  Claim(s) <u>1-6</u> is/are rejected.						
_	•						
	Claim(s) is/are objected to.  Claim(s) are subject to restriction and/o	or election requirement					
ا اره	claim(s) are subject to restriction and/	or election requirement.					
Applicati	on Papers						
9)[	The specification is objected to by the Examin	er.					
10)⊠ The drawing(s) filed on <u>25 March 2004</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
	Replacement drawing sheet(s) including the correct	ction is required if the drawing(s) is ob	jected to. See 37 CFR 1.121(d).				
11)	The oath or declaration is objected to by the E	xaminer. Note the attached Office	Action or form PTO-152.				
Priority u	ınder 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of:							
	<ol> <li>Certified copies of the priority documents have been received.</li> <li>Certified copies of the priority documents have been received in Application No</li> </ol>						
	3. Copies of the certified copies of the priority documents have been received in this National Stage						
	application from the International Burea		Ç				
* S	see the attached detailed Office action for a list		ed.				
Attachment	• •						
	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948)	4) Interview Summary Paper No(s)/Mail Da					
3) 🔯 Infom	nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) No(s)/Mail Date 040604.		Patent Application (PTO-152)				

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## **DETAILED ACTION**

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-6 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nakatsuka et al. (U.S. Patent 4,076,846), in view of Redding, Jr. (U.S. Patent 5,455,342), further in view of Altieri (U.S. Patent 5,849,233). Regarding Claim 1, Nakatsuka et al., hereafter "Nakatsuka," show that it is known to carry out a method for preparing a film (Abstract), the process comprising providing a hydroxyalkyl starch, said starch being derivatized with a hydroxyalkyl substituent having from 2 to 6 carbon atoms (Column 6, lines 60-62); and extruding said starch in an extruder, said extruder having a barrel, a die, and at least one rotating shaft, said barrel having at least first and second zones, said first zone being upstream from said second zone, the temperature in the first zone being insufficient to gelatinize said starch and the temperature in said second zone being sufficient to gelatinize said starch, said starch being extruded in the presence of controlled moisture, said process including the step of controlling the rotational speed of said shaft to impart specific mechanical energy to said starch sufficient to result in a soluble extruded starch product that is capable of extrusion through said die at said rotational speed (Column 8, lines 9-17, 31-33, 49-53; Column 13, lines 31-40; Column 14, lines 5-12, 25-28; It is noted that gelatinization occurs about 150C-175C.), said solution having been prepared by mixing said starch product with water (Column 12, lines 20Art Unit: 1732

24); and forming a film from said solution (Column 4, lines 5-13). Nakatsuka does not specifically disclose the particle size of his common starch. Redding, Jr. shows that it is known to carry out a method of molding starches wherein the starches have a particle size distribution such that at least 90% by weight of the starch particles pass through an 80 mesh (180 micron) screen (Column 1, lines 19-23; It is being interpreted that since starch is "commonly found" at sizes from 5-25 microns, at least 90% by weight of starch would fall into the disclosed size of 5-25 microns.). Redding, Jr. and Nakatsuka are combinable because they are concerned with a similar technical field, namely, methods of molding starches. It would have been prima facie obvious to one of ordinary skill in the art at the time the invention was made to identify the size disclosed in Redding, Jr. as that of Nakatsuka's "common" starches in order to design molding processes that would accommodate specifically-sized granules. Nakatsuka does not specifically show barrel moisture levels. Altieri shows that it is known to carry out a method wherein the moisture in the barrel does not exceed 25% by weight of said starch (Column 1, lines 56-58). Altieri and Nakatsuka are combinable because they are concerned with a similar technical field, namely, methods of molding starches. It would have been prima facie obvious to one of ordinary skill in the art at the time the invention was made to use Altieri's specific barrel moisture teachings during Nakatsuka's molding process in order to most accurately form a product that accommodates exclusive end-use specifications.

Regarding Claim 2, Nakatsuka shows the process as claimed as discussed in the rejection of Claim 1 above, but he does not give barrel moisture levels. Altieri shows that it is known to carry out a method wherein the moisture in the barrel does not exceed 25% by weight of said starch (Column 1, lines 56-58). It is noted that a prior art reference that discloses a range encompassing a somewhat narrower claimed range is

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sufficient to establish a prima facie case of obviousness (MPEP 2144.05; In re Peterson, 315 F.3d 1325, 1330, 65 USPQ2d 1379, 1382-83 (Fed. Cir.2003). It would have been prima facie obvious to one of ordinary skill in the art at the time the invention was made to operate Nakatsuka's molding method under a somewhat narrower moisture range of less than 22.5% by weight of the starch, suggested by Altieri, in order to most accurately form a product that accommodates exclusive end-use specifications.

Regarding Claim 3, Nakatsuka shows the process as claimed as discussed in the rejection of Claim 1 above, but he does not give barrel moisture levels. Altieri shows that it is known to carry out a method wherein the moisture in the barrel does not exceed 25% by weight of said starch (Column 1, lines 56-58). It is noted that a prior art reference that discloses a range encompassing a somewhat narrower claimed range is sufficient to establish a prima facie case of obviousness (MPEP 2144.05; *In re Peterson*, 315 F.3d 1325, 1330, 65 USPQ2d 1379, 1382-83 (Fed. Cir.2003). It would have been prima facie obvious to one of ordinary skill in the art at the time the invention was made to operate Nakatsuka's molding method under a somewhat narrower moisture range of less than 20% by weight of the starch, suggested by Altieri, in order to most accurately form a product that accommodates exclusive end-use specifications.

Regarding Claim 4, Nakatsuka shows the process as claimed as discussed in the rejection of Claim 1 above, but he does not give barrel moisture levels. Altieri shows that it is known to carry out a method wherein the moisture in the barrel does not exceed 25% by weight of said starch (Column 1, lines 56-58). It is noted that a prior art reference that discloses a range encompassing a somewhat narrower claimed range is sufficient to establish a prima facie case of obviousness (MPEP 2144.05; *In re Peterson*, 315 F.3d 1325, 1330, 65 USPQ2d 1379, 1382-83 (Fed.

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Cir.2003). It would have been prima facie obvious to one of ordinary skill in the art at the time the invention was made to operate Nakatsuka's molding method under a somewhat narrower moisture range of less than 17.5% by weight of the starch, suggested by Altieri, in order to most accurately form a product that accommodates exclusive end-use specifications.

Regarding Claim 5, Nakatsuka shows the process as claimed as discussed in the rejection of Claim 1 above, including a method wherein the solution includes a plasticizer (Abstract), meeting applicant's claim.

Regarding Claim 6, Nakatsuka shows the process as claimed as discussed in the rejection of Claim 1 above, including a film formed by the said process (Column 4, lines 5-13), meeting applicant's claim.

## Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Monica A. Huson whose telephone number is 571-272-1198. The examiner can normally be reached on Monday-Friday 6:45am-3:15pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Christina Johnson can be reached on 571-272-1176. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Monica A Huson

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August 7, 2006